IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: 10/675,419 Art Unit: 1756

Applicant: John M. Kulp

Title: SACRIFICIAL SURFACTANATED PRE-WET FOR DEFECT

REDUCTION IN A SEMICONDUCTOR PHOTOLITHOGRAPHY

DEVELOPING PROCESS

Attorney Docket: CT-001 Confirmation No.: 6182

Cincinnati, OH February 9, 2007

Mail Stop AF

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

AMENDMENT AFTER FINAL

This paper is responsive to the final Office Action mailed October 11, 2006. The Examiner has indicated that claims 1-35 are pending in the application and are rejected. The present response includes the following:

Amendments to the Specification: None

Amendments to the Claims: Pages 2-9

Amendments to the Abstract: None
Amendments to the Drawings: None

Remarks: Pages 10-12

Attachments: None